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## **전 고성박막전지의 개발 및 응용**

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**남 상 철 연구소장**

(주) 누리셀 마이크로셀 센터)



# 전 고상박막전지의 개발 및 응용

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㈜ 누리셀 마이크로셀 센터

남상철, 박호영

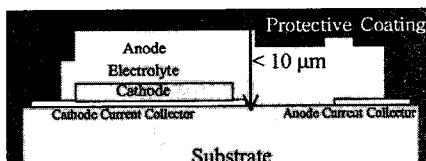
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## What is Thin Film Battery?

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- All solid state components
- Thin film fabrication of all battery components



Schematic cross section

### Advantages

- possible to make flexible & nude
- variety of shapes and size
- absence of possible pollution
- thermal stability (wide working temp.)
- low self-discharge
- easy to mass-production
- combine with imbedded devices
- Good cyclability

### Disadvantages

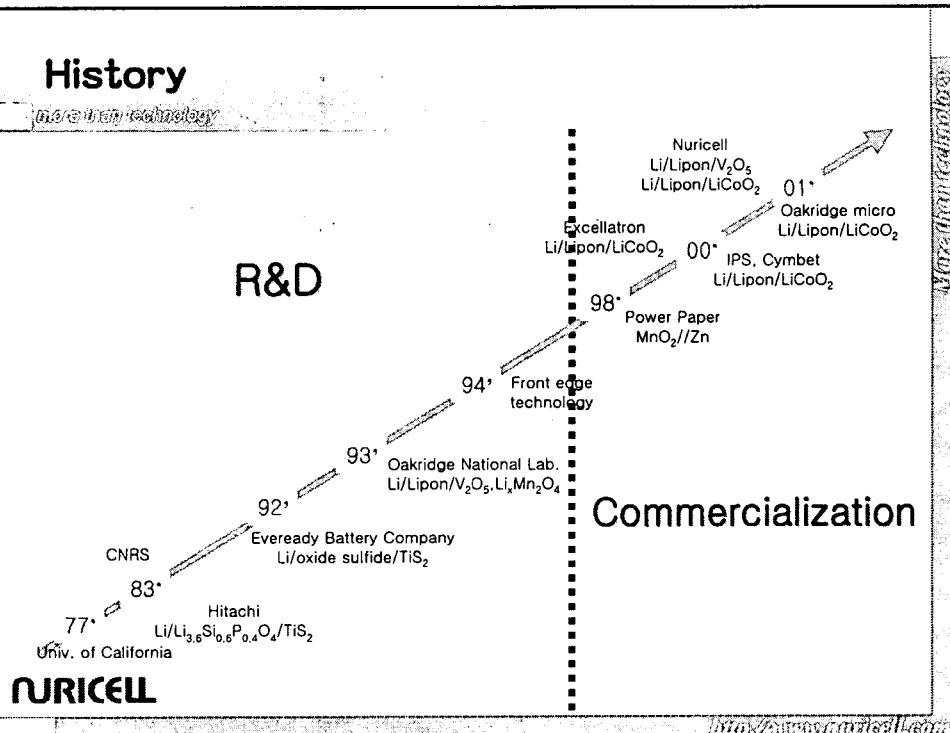
- The current densities are limited because of the high internal resistance
- Low ionic conductivity of the electrolyte
- Low capacity because of small mass of active materials

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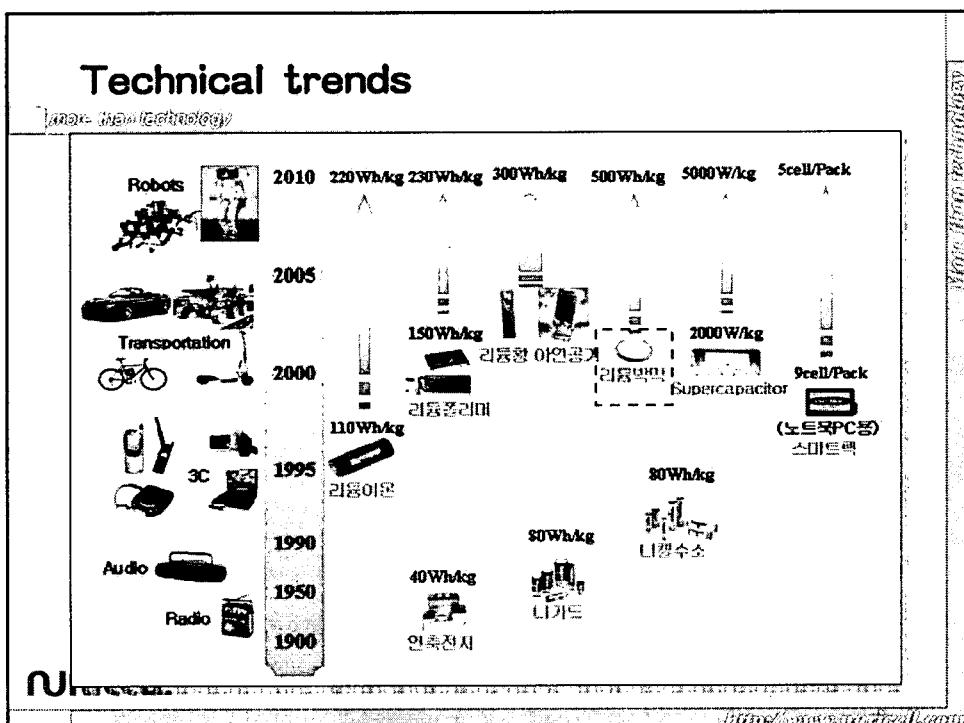
## History

new & new technology



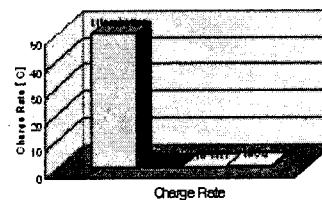
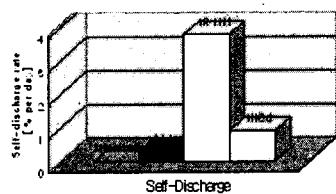
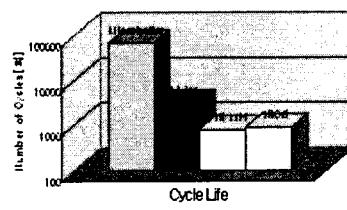
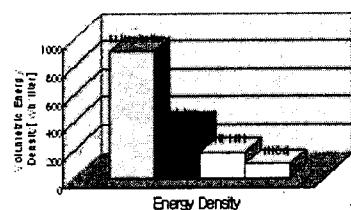
## Technical trends

new & new technology



## Performance of TFB

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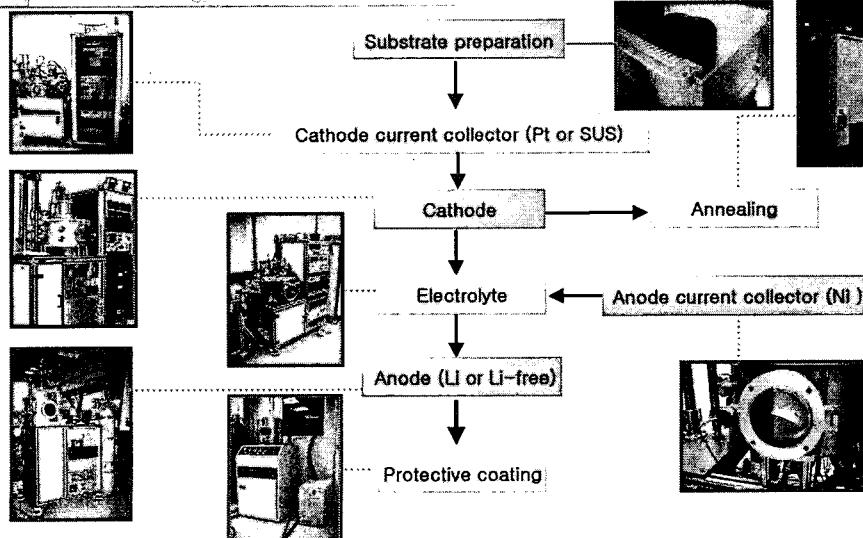
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## Fabrication Steps

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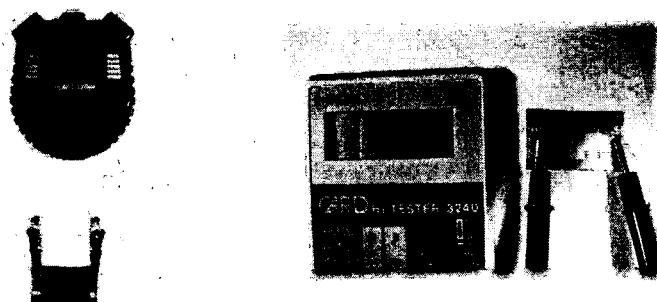


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## Prototype

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- Prototype of Nuricell Inc. : unit cell on polymer film
- Voltage : 1.5 ~ 3.4 V
- It works a stopwatch for 2 weeks.

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## Comparison with other batteries

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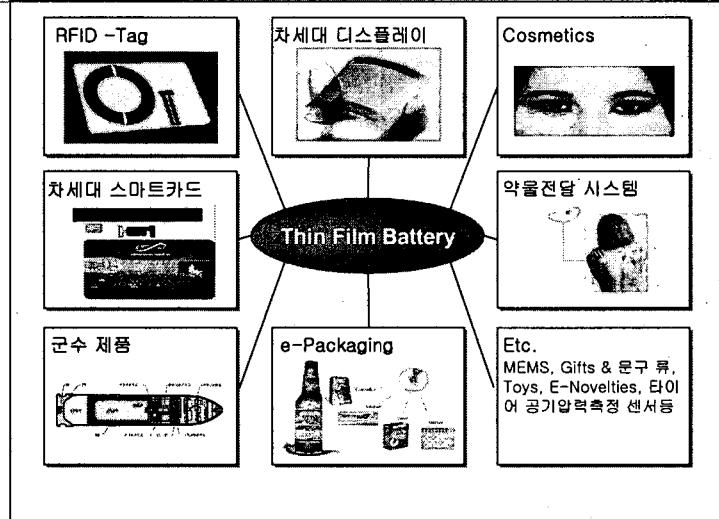
Parameter	Cymbet (0.25 cm <sup>2</sup> , on silicon)	Dallas/Maxim (PowerCap)	STMicroelectronics (SNAPHAT)
Charge Capacity	90 µAh (x 10,000 cycles)	130mAh (not rechargeable)	130 mAh (not rechargeable)
Thickness (mils)	2	215	385
Price (each, in volume)	\$ 0.25	\$ 3.43	\$ 3.55
Integration	In IC package	External circuit board	Snap-on package
Operating Temperature	-40 to +150°C	0 to +70°C	-40 to +85°C

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## Main applications

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## An approach to thin film battery development

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### LiCoO<sub>2</sub> cathode

Thin film process for LiCoO<sub>2</sub> has not been thoroughly investigated.

It is difficult to fabricate the complete TFB due to defects by high temp. annealing.

Change of sputtering pressure as a process parameter

Low temp. annealing process

Control of Structural evolution & composition

Reducing the thermally induced problems

### LiPON electrolyte

Can not clearly define the trend for LiPON properties with process condition due to non-equilibrium synthesis.

Change of nitrogen pressure as a process parameter

Improvement of ionic conductivity & stability window

Characterization of LiCoO<sub>2</sub> thin film cathode & LiPON thin film solid electrolyte

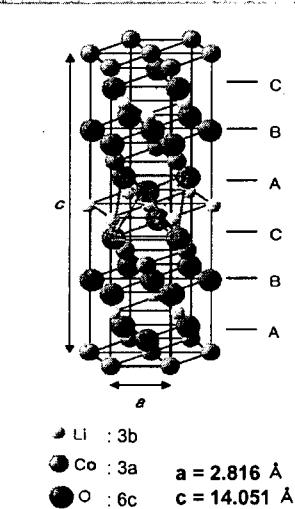
Optimal condition for TFB

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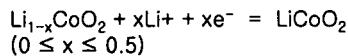
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## Basic properties of $\text{LiCoO}_2$ cathode

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### 1. Reaction :



Practical capacity : 137 mAh/g

Open circuit voltage : 4.1 V (vs. Li /  $\text{Li}^+$ )

### 2. Crystal Structure :

Layered metal oxide with O<sub>3</sub> type ( $\alpha\text{-NaFeO}_2$ )

Space group R-3m

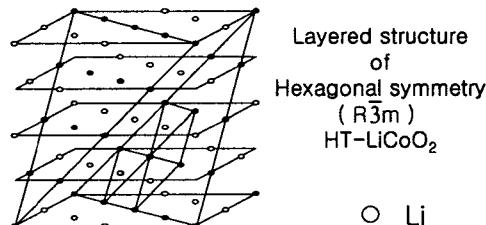
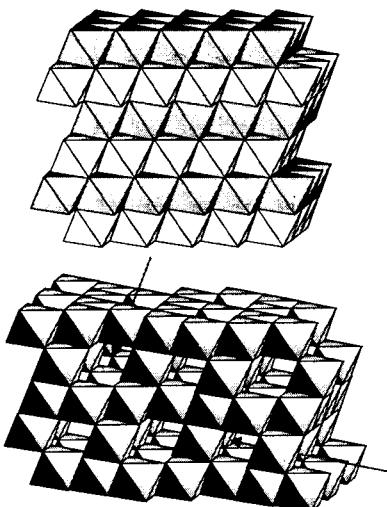
Oxygen stacking sequence of ABCABC.....

Consist of edge-shared oxygen octahedron

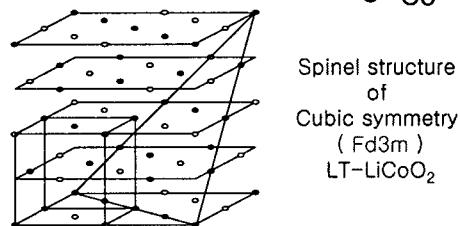
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## Crystal structure of $\text{LiCoO}_2$ cathode

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○ Li  
● Co

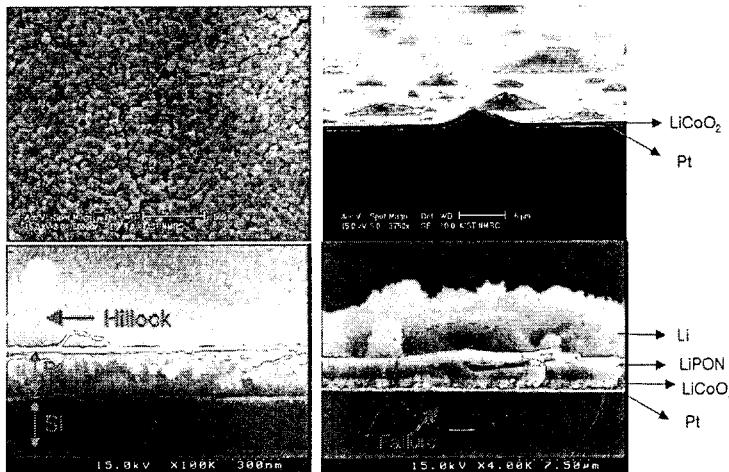


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## Defects induced by HT-annealing at 650°C

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Annealing to crystallize LiCoO<sub>2</sub> cathode → Thermal Budget → Stress release → Mass transport → Hillock or Buckling of Pt → Cathode cracking → Cell failure

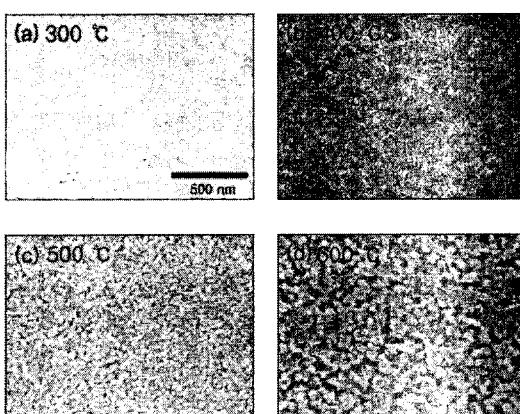


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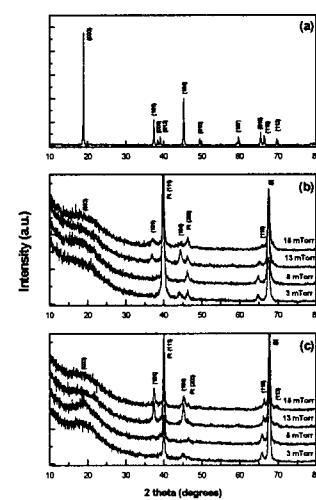
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## SEM & XRD of LiCoO<sub>2</sub> thin films

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In-situ annealing by hot stage SEM



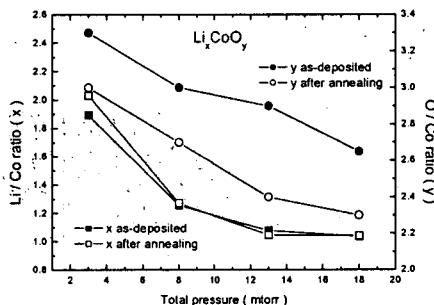
XRD Patterns  
(a) Target (b) As-depo (c) 400°C

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## Comparison of compositions

Li : Co ratio by ICP-AES  
 O : Co ratio by RBS

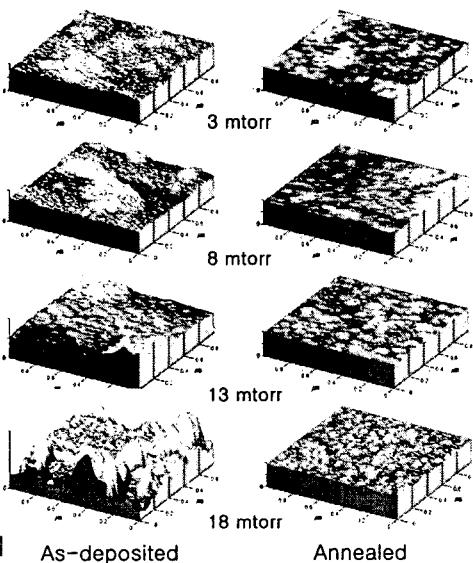


1. Excess of Li & O, but as pressure  $\uparrow$ , Li & O  $\downarrow$   
 ( $\because$  re-sputtering of Li at higher pressure, Li  $\propto$  O)
2. Constant Li before & after annealing, but O  $\downarrow$  after annealing  
 ( $\because$  corner shared octahedron  $\rightarrow$  edge shared octahedron by grain growth)

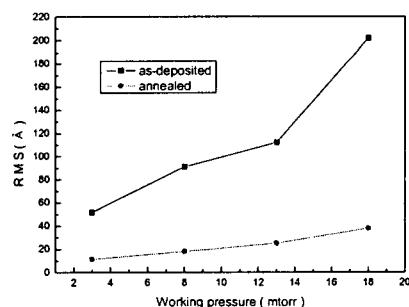
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## AFM micrograph & Roughness

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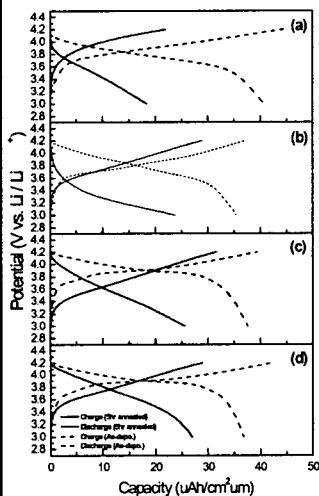


RMS Roughness data

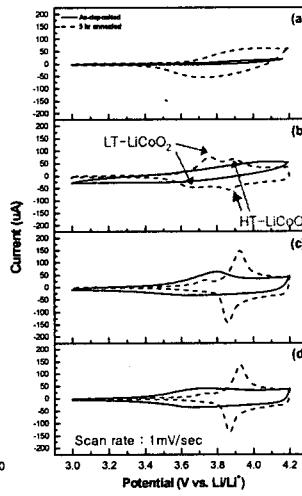


## Electrochemical properties of $\text{LiCoO}_2$ thin films

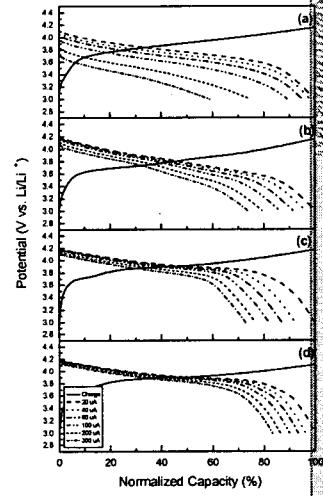
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Charge-discharge characteristics



Cyclic Voltammograms



Rate capability

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Sputtering pressure : (a) 3 mtorr (b) 8 mtorr (c) 13 mtorr (d) 18 mtorr

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## Electrolyte (Why LiPON ?)

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### Polymer electrolyte

→ *Difficulty to make a thin film*

### Inorganic crystalline materials

→ *Need heat treatment to make a crystalline structure*

### Sulfide electrolyte

→ *Environmental problems*

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Highly stable at atmospheric condition

Pretty high ionic conductivity ( $\sim 10 \times 10^{-6} \text{ S/cm}$ )

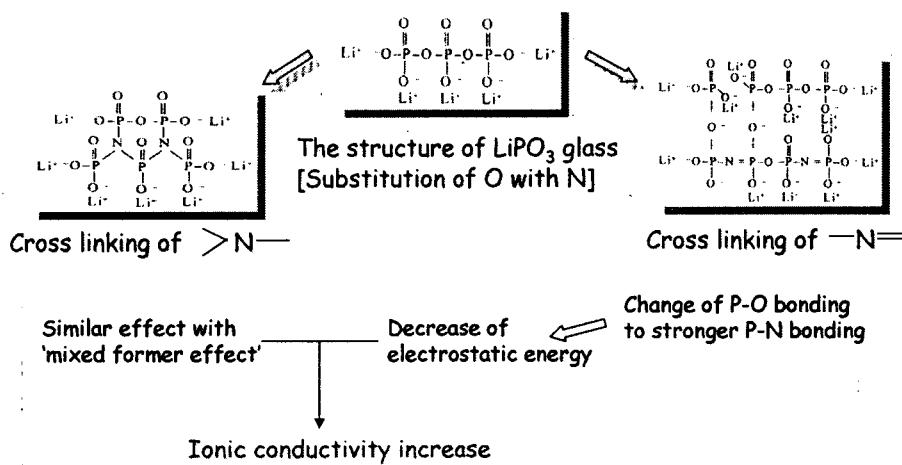
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## Electrolyte (Mechanism)

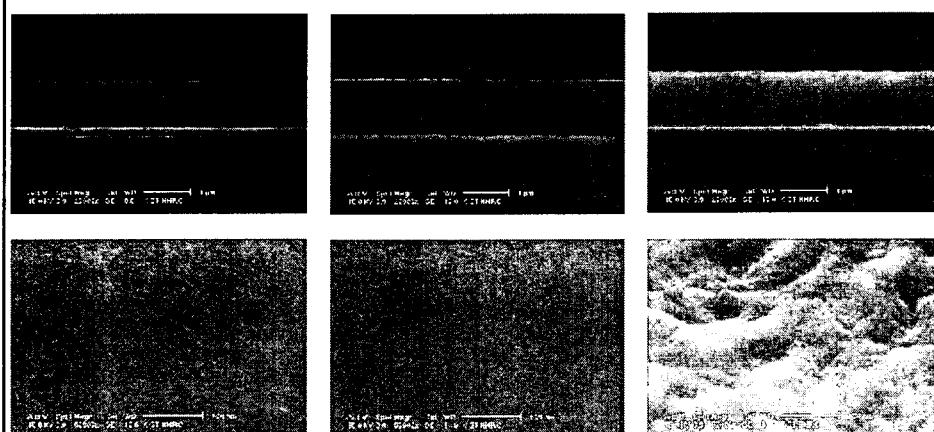
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## SEM images of LiPON films

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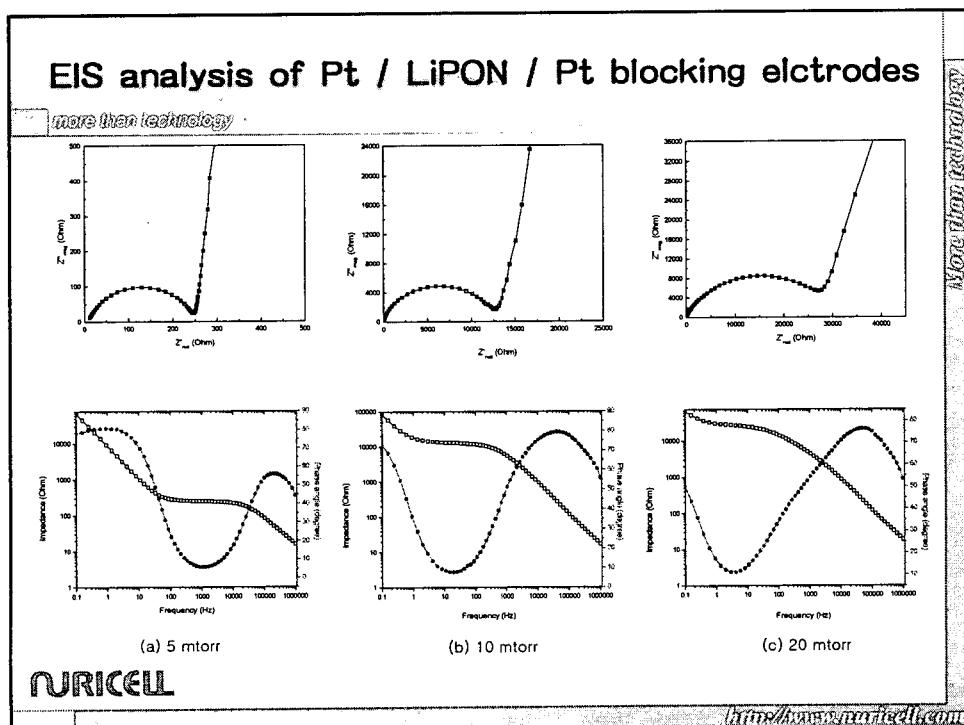
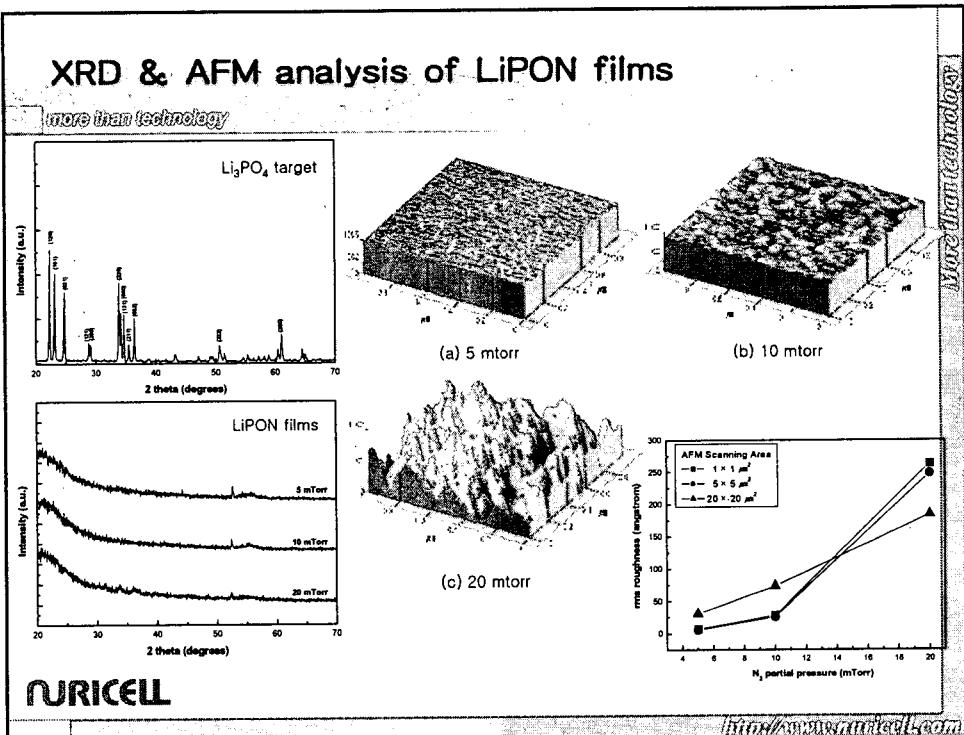
(a) 5 mtorr

(b) 10 mtorr

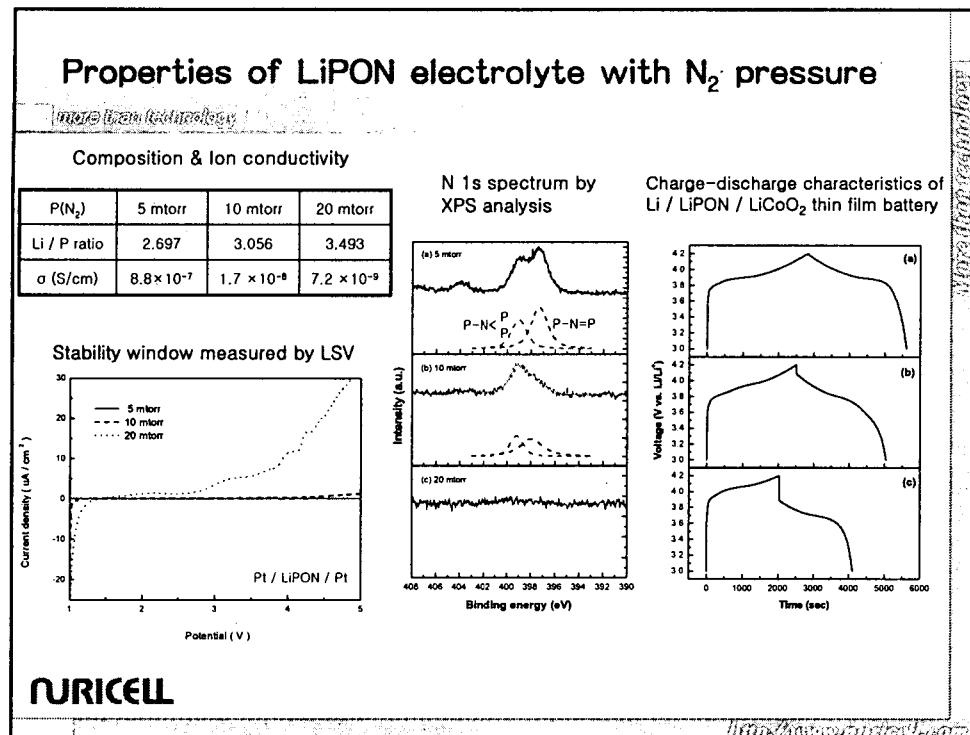
(c) 20 mtorr

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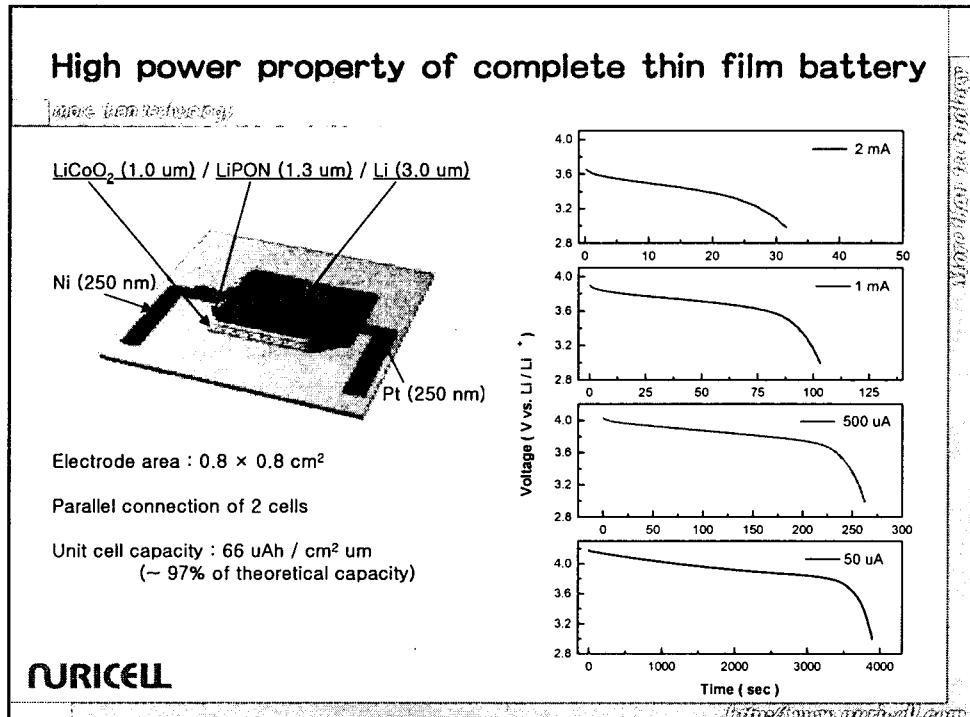
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## Properties of LiPON electrolyte with N<sub>2</sub> pressure



## High power property of complete thin film battery



## Conclusions

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Cell array?  
Process architecture?  
Optimum design?



Process

Applications  
Process set-up  
Scale-up

Design

Applications

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## Foreign activities

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